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Improved Low Voltage SEM Image Resolution Through The Use of Restoration Techniques

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Previous Work: Improved Resolution of LaB_6

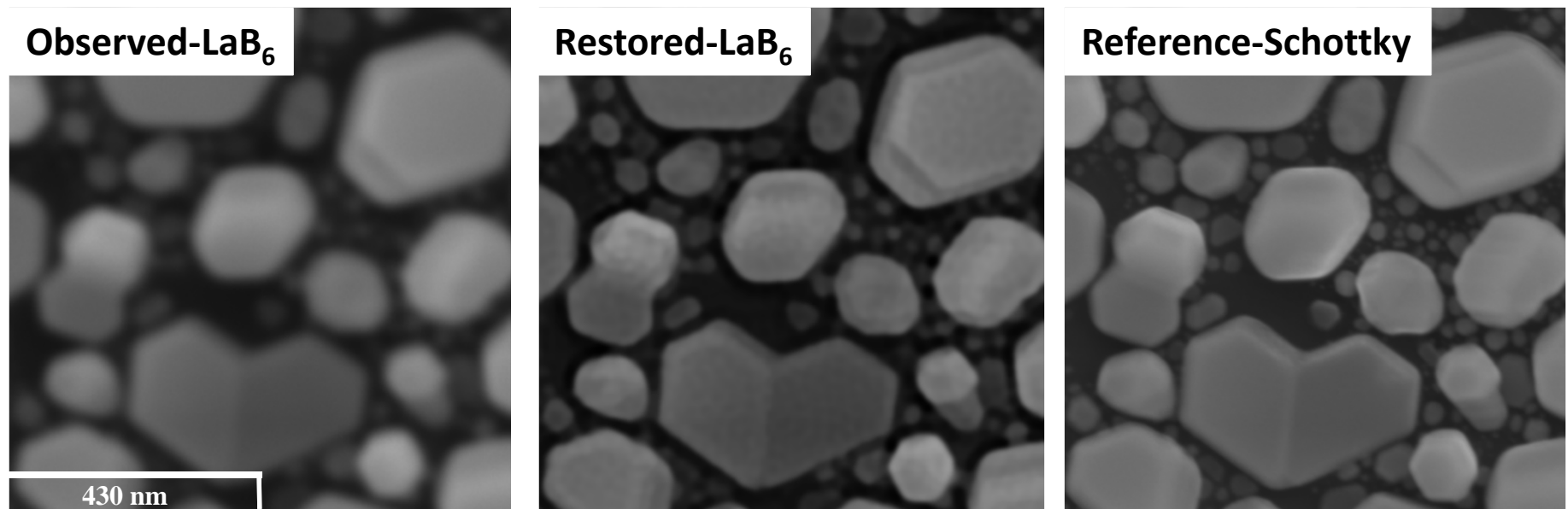


Image Degradation: Convolution & Noise

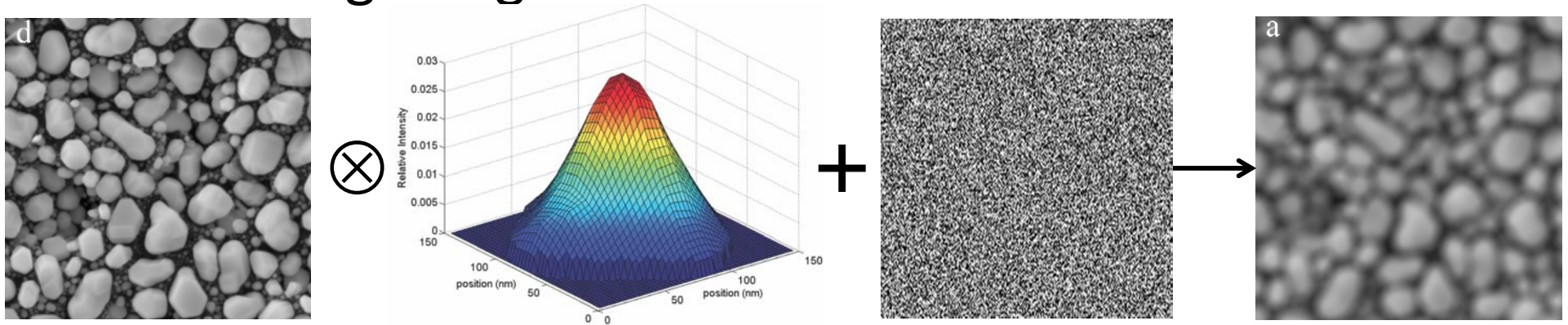
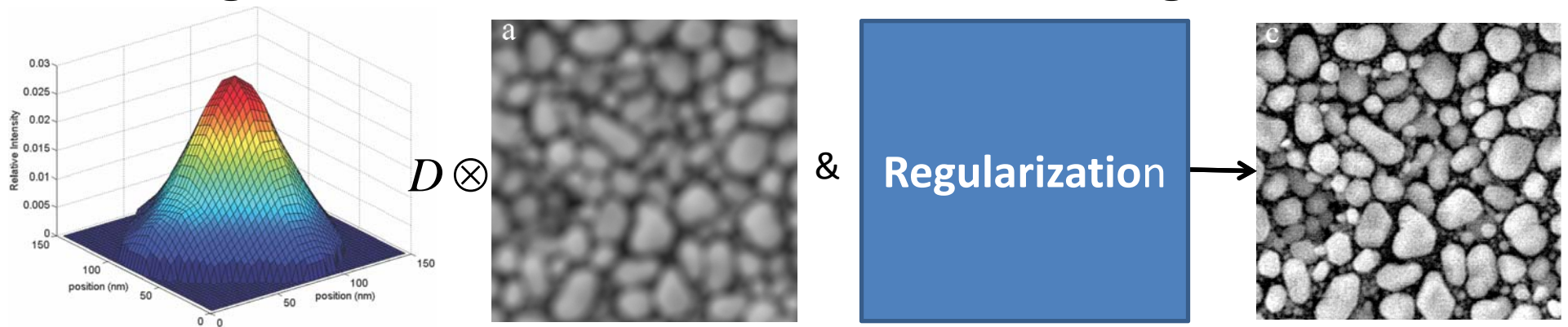


Image Restoration: Deconvolution & Regularization



Our Image Restoration Scheme

$$1. I_{obs} = psf(x, y) \otimes I_{True} + \mathbf{k}$$

$$2. \vec{b} = \mathbf{A}\vec{x} + \vec{k}; \vec{x} \geq 0$$

$$3. f(x) = \underset{x}{\operatorname{argmin}} \{ \|\mathbf{A}\vec{x} - \vec{b}\|_2^2 + \lambda R(\vec{x}) \} \quad s.t. \quad \vec{x} \geq 0$$



For More on PSF Determination:

352 - Measurement of the Electron Beam Point Spread Function (PSF) in a Scanning Electron Microscope (SEM):

Session [A16.01 - Advances in Electron and Ion Scanning Microscopies](#)

Location B118

Date Tuesday, Aug 4 2:00 PM

Duration 15 minutes



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Process Flow

1. Obtain reference image with reference microscope for a standard sample area
2. Obtain observed image with same sample area on observation microscope
3. Determine the PSF of the observation microscope based on equation 1 of previous slide
4. Use the determined PSF of the observation microscope to restore images taken with similar operating conditions

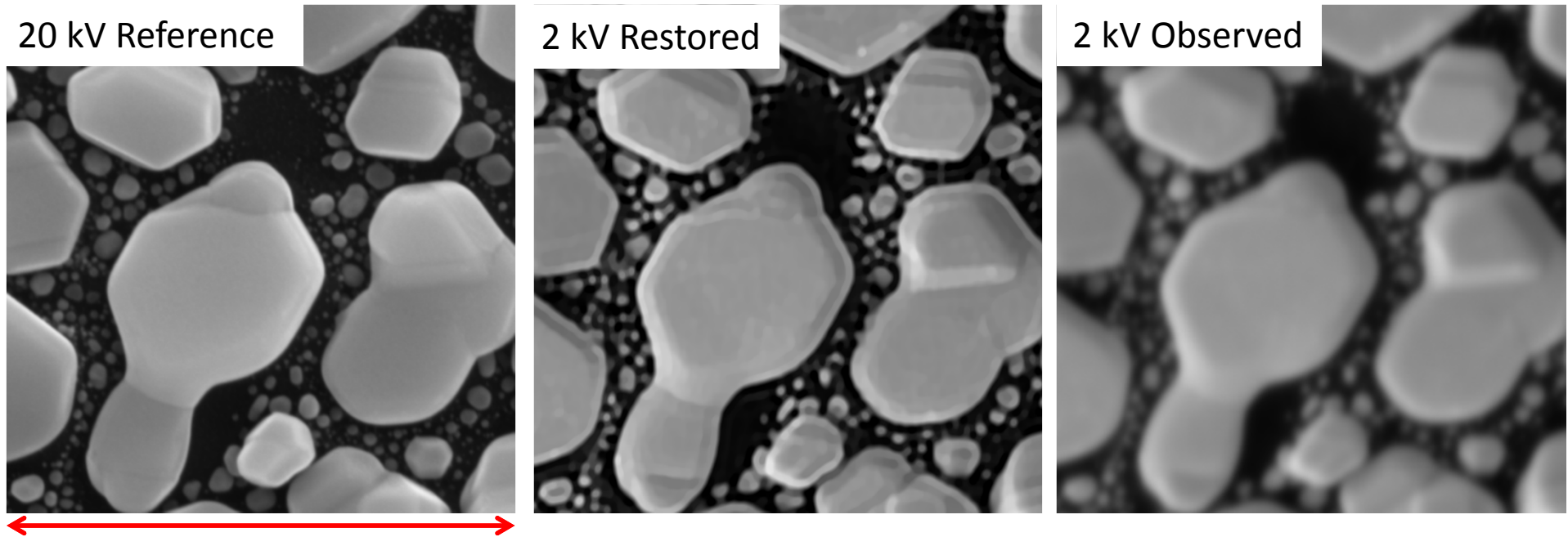


Improved Low Voltage Operation

- Step 1: Use high kV, high resolution image as a reference for PSF determination for low kV observation.
- Step 2: Restore low kV, observed images using PSF determined from Step 1.
- Motivation:
 - Not every user has a beam decelerator for low kV operation
 - Beam deceleration may not be applicable to all samples



Schottky Low kV Restoration: Au



FOV = 880 nm

This reference image pair used to determine the PSF at low voltage

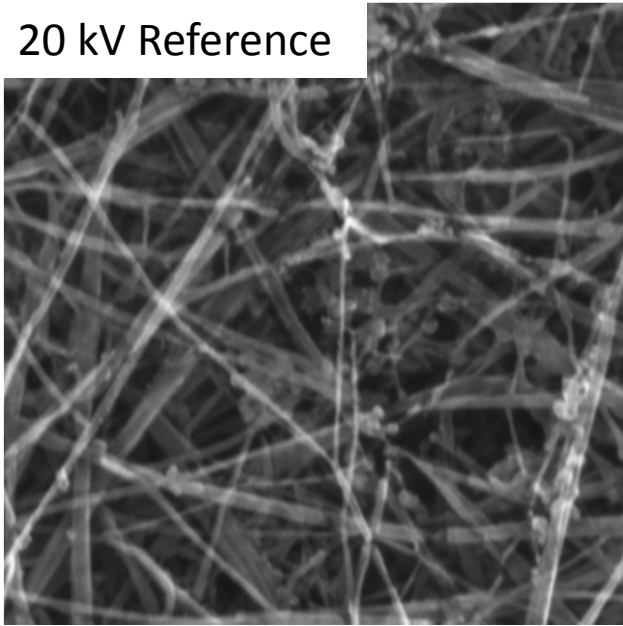


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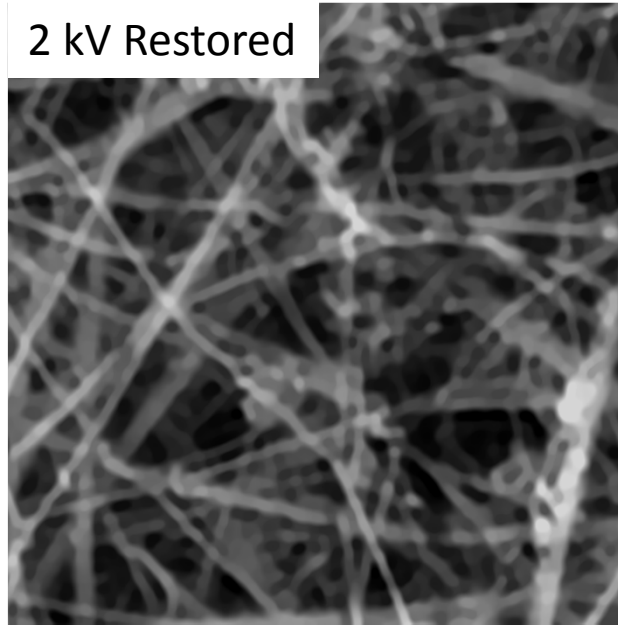
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Schottky Low kV Restoration: C-Nanotubes

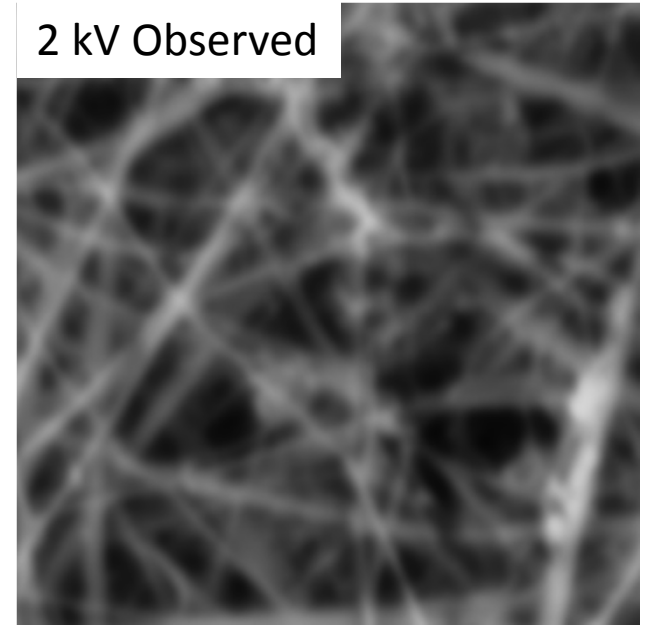
20 kV Reference



2 kV Restored



2 kV Observed



FOV = 880 nm

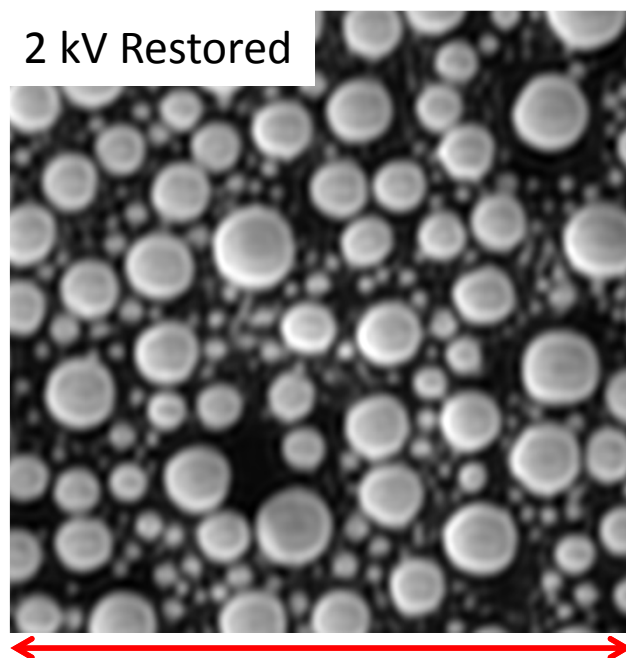
Restored with PSF determined
from the Au sample!



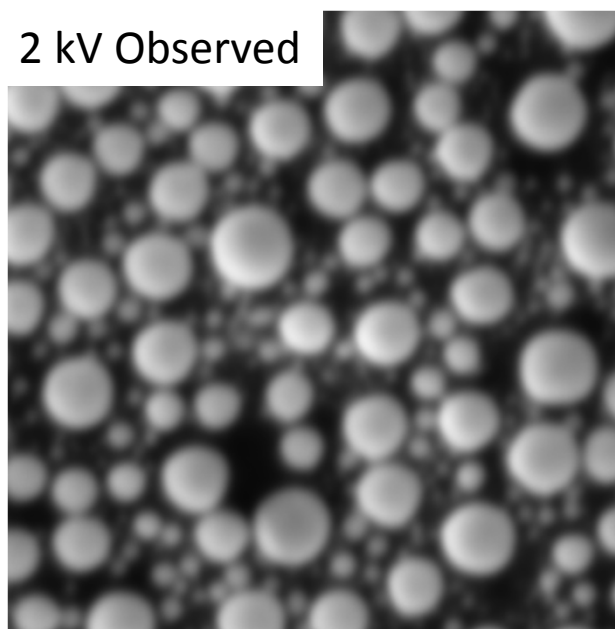
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Schottky Low kV Restoration: Sn



FOV = 880 nm



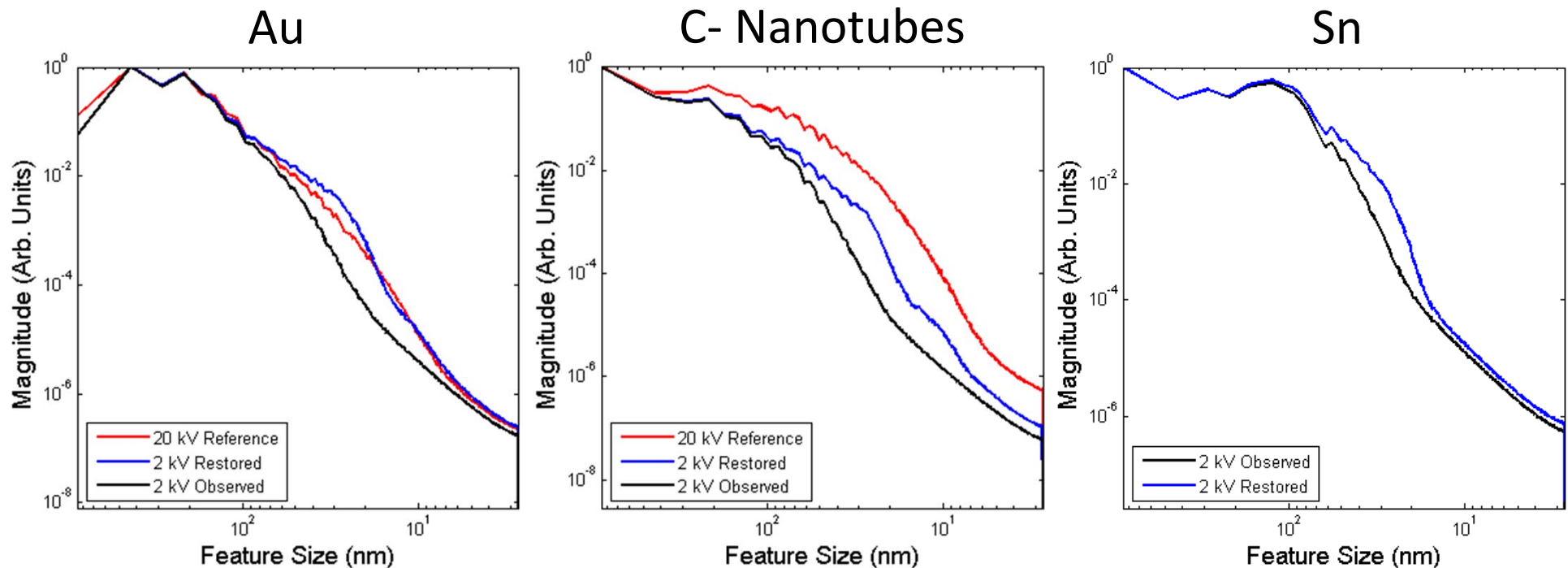
Restored with PSF determined
from the Au sample!



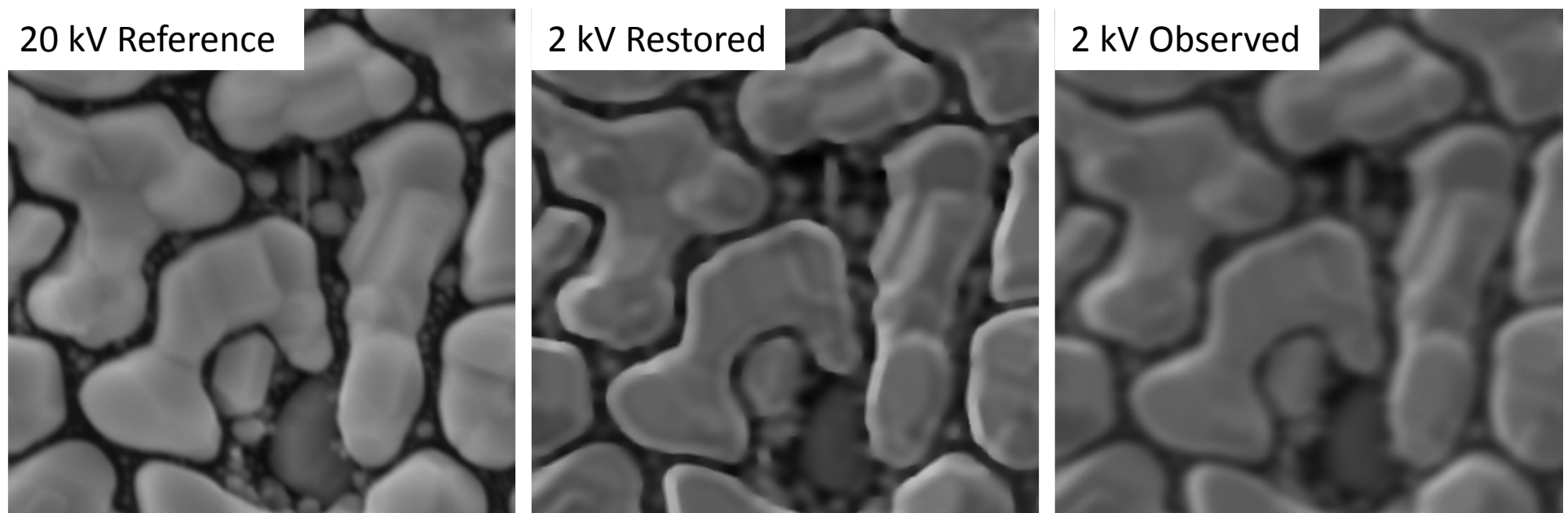
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CTF Plots: Au, C-Nanotubes, Sn



LaB₆ Low kV Restoration: Au



FOV = 4.34 μm

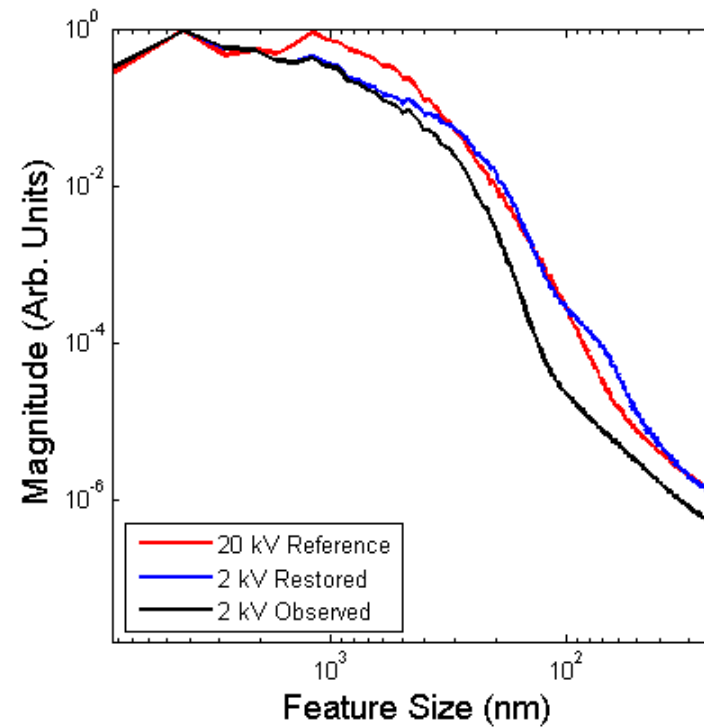
This reference image pair used to determine the PSF at low voltage



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CTF Plot: LaB₆ Restoration



Conclusions

- Successfully shown that it is possible to use a single microscope to improve low kV performance without beam deceleration
- Even with different contrast mechanisms between kVs, we are able to determine useful PSFs
- Although thermionic sources are traditionally not used at low kV, our work opens the possibility of improved low kV imaging on such instruments



Future Work

- How low can we go in kV on a thermionic source and still achieve measurable improvement?
- Incorporate additional factors into restoration method:
 - Adjustments in secondary electron yield
 - SE1/SE2 ratio variation with voltage
 - Optimization of restoration algorithm



Acknowledgements

- Tescan
- Jeffery Moskin
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Questions?

352 - Measurement of the Electron Beam Point Spread Function (PSF) in a Scanning Electron Microscope (SEM):

Session [A16.01 - Advances in Electron and Ion Scanning Microscopies](#)

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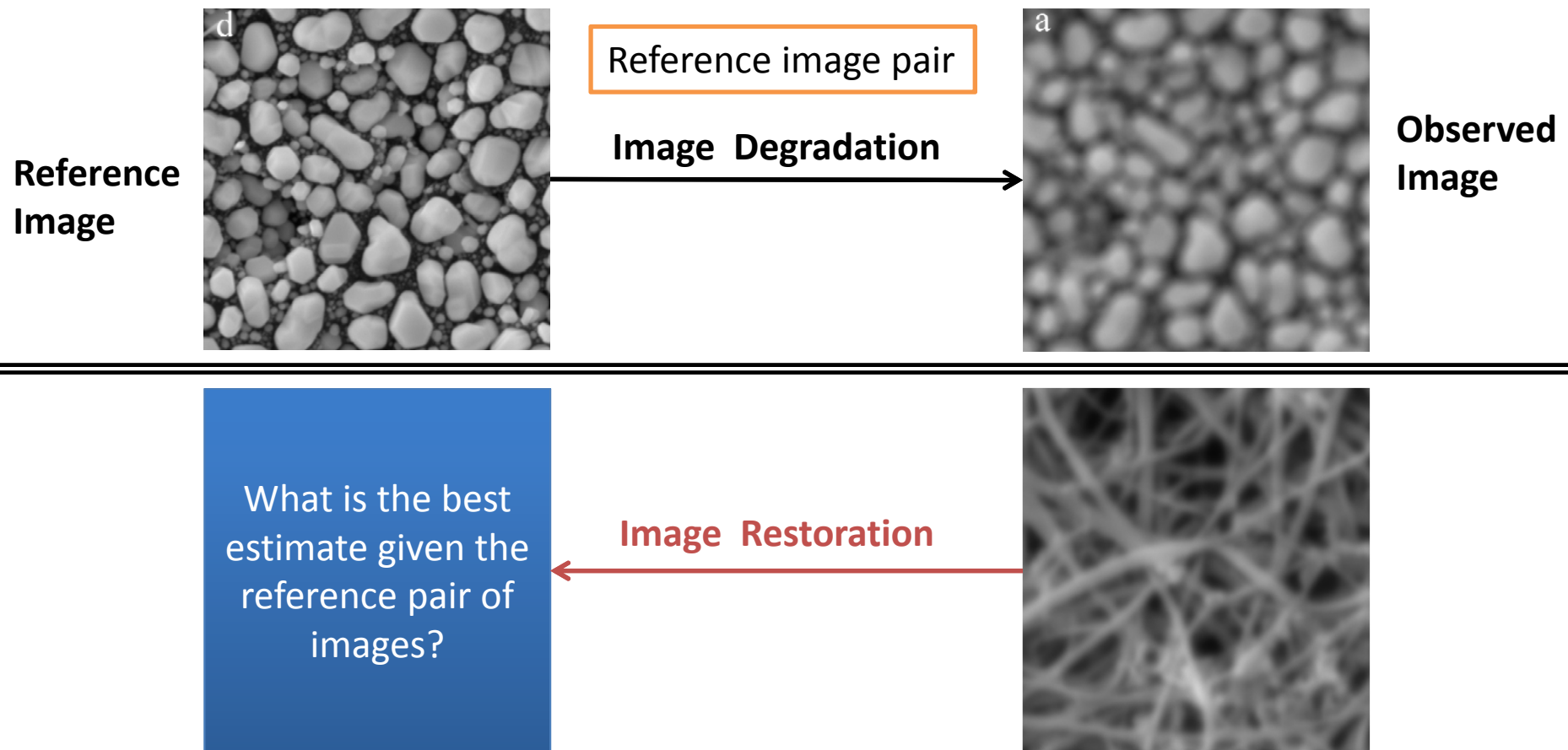
Duration 15 minutes



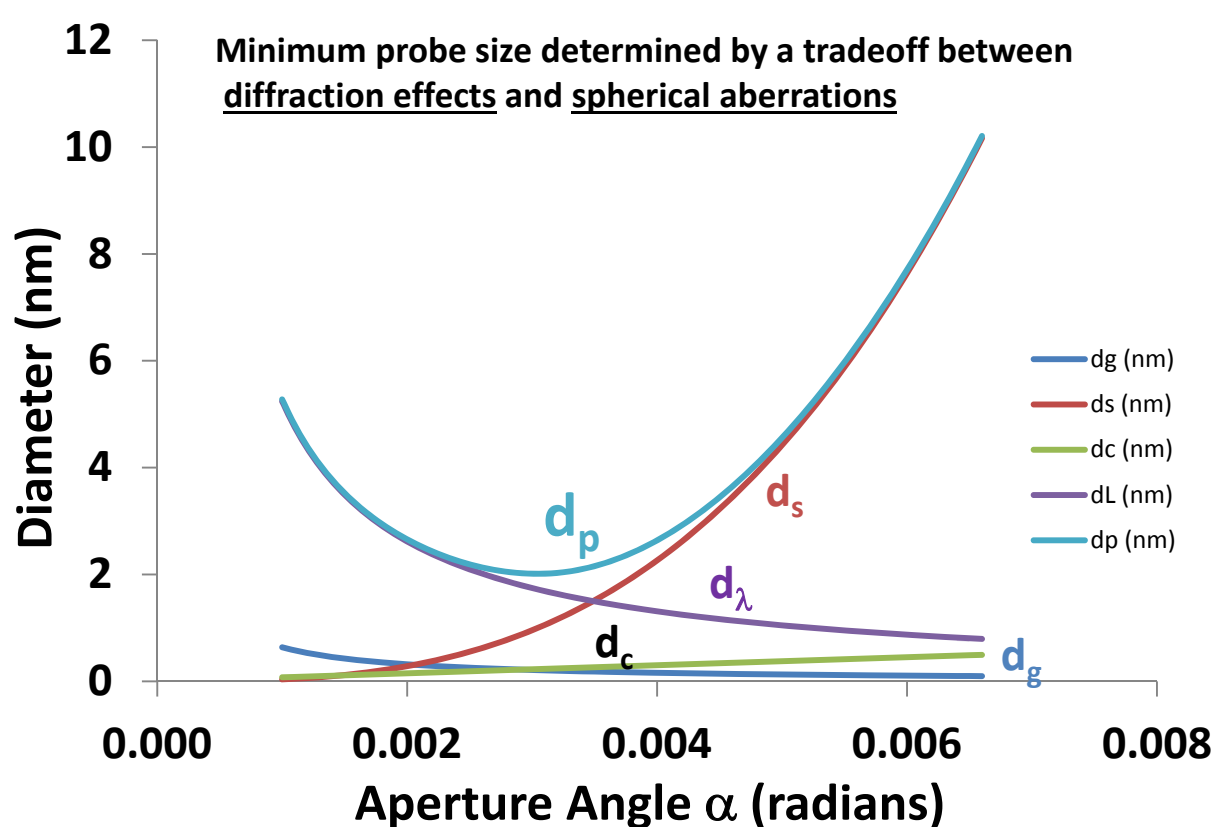
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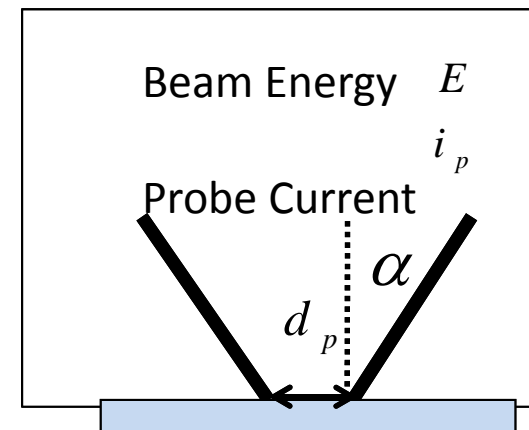
Image Restoration



Probe Diameter tradeoff - Schottky 20 keV¹⁹

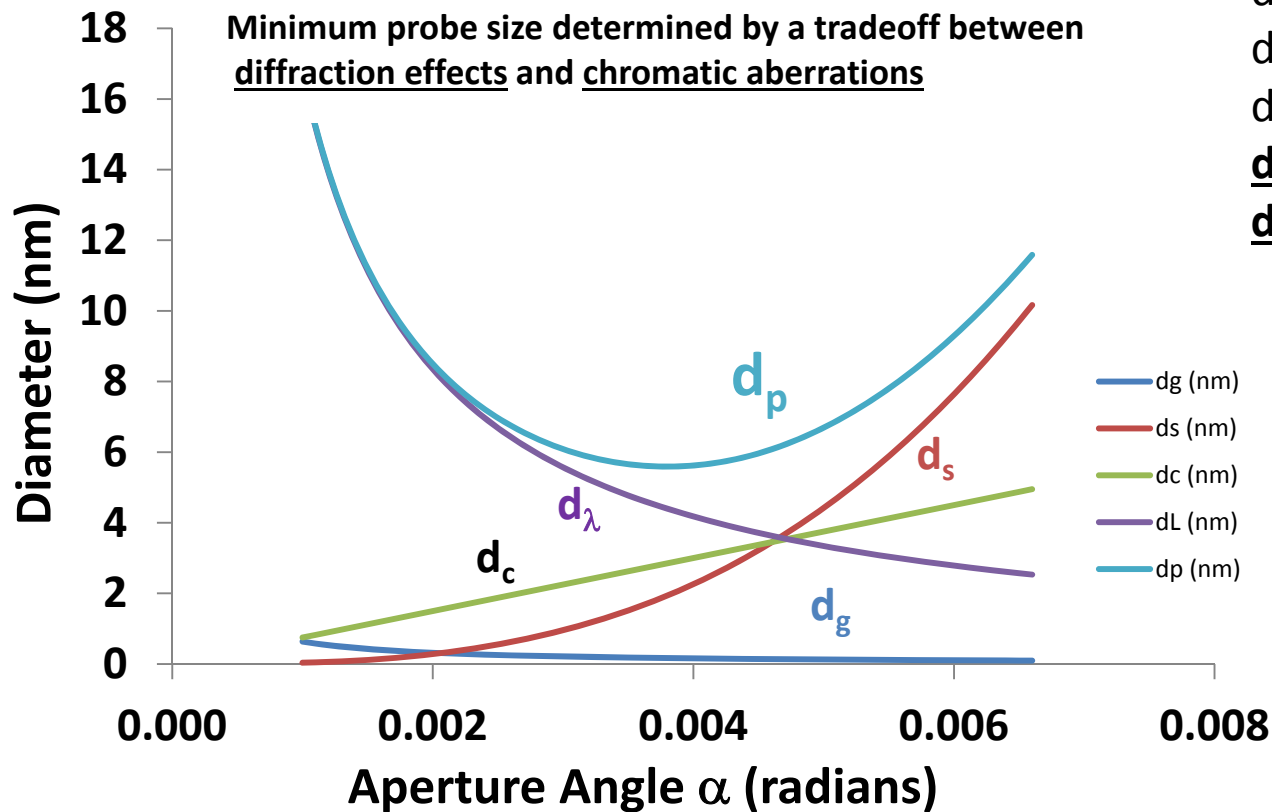


d_p – Probe Diameter
 d_g – Source Demagnification
 d_s – Spherical Aberrations
 d_c – Chromatic Aberrations
 d_λ – Diffraction Effects

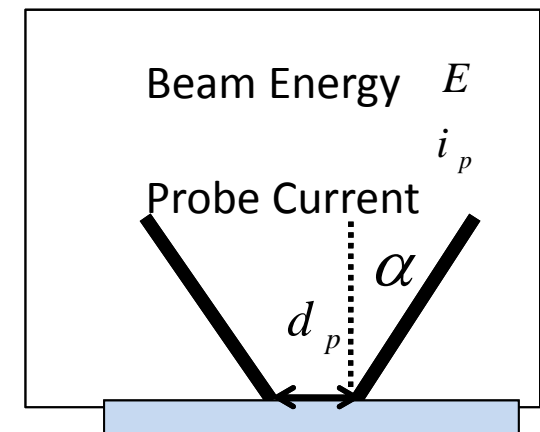


Schottky Source: $E = 20 \text{ KeV}$, $\Delta E = .4 \text{ eV}$, $\beta = 1 \times 10^8 \text{ Amps/cm}^2\text{sr}$ and $i_p = 10 \text{ pA}$

Probe Diameter tradeoff - Schottky 2 keV



d_p – Probe Diameter
 d_g – Source Demagnification
 d_s – Spherical Aberrations
 d_c – Chromatic Aberrations
 d_λ – Diffraction Effects

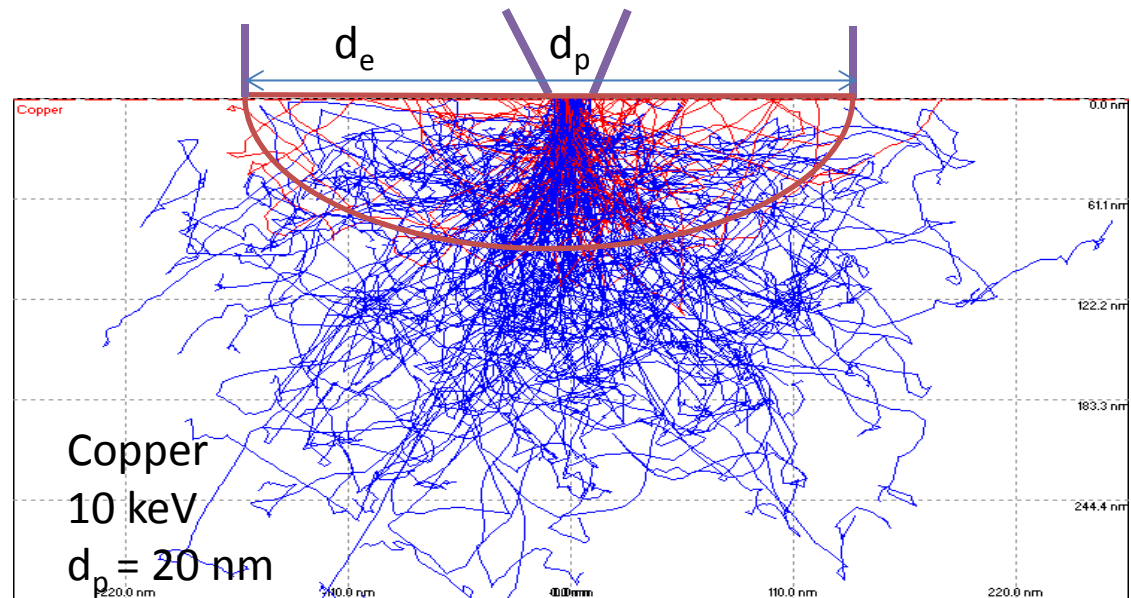


Schottky Source: $E = 2 \text{ KeV}$, $\Delta E = .4 \text{ eV}$, $\beta = 1 \times 10^8 \text{ Amps/cm}^2\text{sr}$ and $i_p = 10 \text{ pA}$

SEM resolution is limited by the probe size, d_p , surface morphology and excitation volume, d_e .

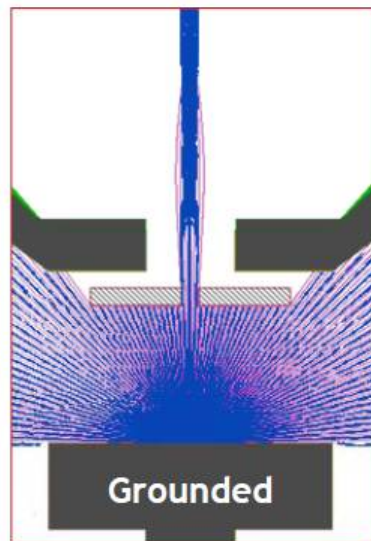
- For backscattered electrons d_e can be \gg than d_p unless low kV are used
- For type 1 secondary electrons d_e can be almost equal to d_p

For planar samples d_p is not sample dependent. d_e is !

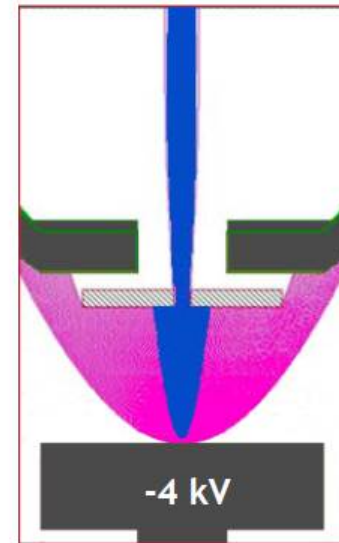


Conventional Techniques: Beam Deceleration

BD mode OFF
no sample bias



BD mode ON
maximum sample bias



SE
BSE



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What determines the probe size, d_p ?

$$d_p = \sqrt{(d_g^2 + d_s^2 + d_c^2 + d_\lambda^2)}$$

where

Source Demagnification: $d_g = Md_0 = \sqrt{\left(\frac{4i_p}{\pi^2\beta}\right)}\alpha^{-1}$

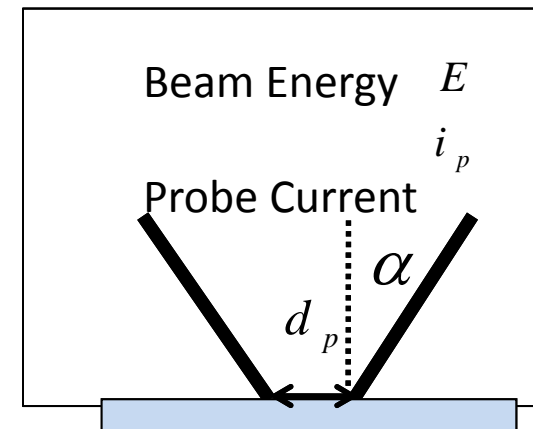
Spherical Aberrations: $d_s = \sqrt{\frac{C_s}{4}}\alpha^3$

Chromatic Aberrations: $d_c = C_c\left(\frac{\Delta E}{E}\right)\alpha$

Diffraction Effects: $d_\lambda = .61\lambda\alpha^{-1}$

Wavelength: $\lambda = h / mv = 1.226 / \sqrt{E}$

Brightness: $\beta \cong \frac{j_c E}{\pi k T_c}$



$\lambda = 8 \text{ pm}$ at 30 KeV

$d_\lambda = .8 \text{ nm}$ for $\alpha = .006$ radians



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Outline

- Previous Work
- Image Restoration
- Application for Low kV
- Examples: Thermionic and Field Emission
- Future Directions

